

Electron kinetics in fast-pulsed discharges

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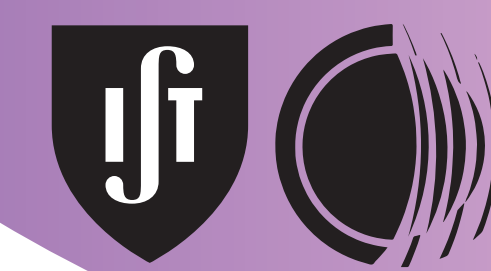
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Introduction

Predictive tools for non-equilibrium low-temperature plasmas (LTPs) should describe properly the **kinetics of electrons**, responsible for **inducing plasma reactivity**. Here, we focus on plasmas produced in N₂-O₂ gaseous mixtures, aiming to deliver a **Kinetic Testbed for PLASMA Environmental and Biological Applications (KIT-PLASMEBA)** [1], comprising the development of simulation tools and the critical assessment of collisional-radiative data.

In this framework, we have developed the **LisOn Kinetics Boltzmann solver (LoKI-B)** [2,3], an **open-source MATLAB®** simulation tool that solves a time and space independent form of the

two-term electron Boltzmann equation (EBE), for non-magnetized non-equilibrium LTPs created from different gases or gas mixtures. The simulation tool gives a microscopic description of the electron kinetics and calculates macroscopic quantities, such as **electron impact rate coefficients and electron transport parameters**.

Recently, there has been increasing interest in non-equilibrium LTPs created by **fast-pulsed discharges**, because of their potential advantages in different technological applications [4]. In this work, we present the recent developments introduced in LoKI-B in order to **improve the description of the electron kinetics in fast-pulsed discharges**.



Fast-pulsed discharges

The typical timescale of the breakdown, for gases at elevated pressures, ranges from the **nanosecond to the microsecond scale**. Changing the applied voltage during this crucial process greatly affects the plasma parameters and composition. With the advent of non-equilibrium plasmas at atmospheric pressures for many applications, discharges generated by voltage pulses with rise times up to hundreds of volts per nanosecond (or even higher) have become a **promising technique to tune the plasma for each specific application** [4].

Here, **global models** represent a simple, yet powerful, tool to study and understand plasmas produced by fast-pulsed discharges. One of the main pieces of information that is needed in a global model refers to electron parameters (rate coefficients, transport parameters, etc). This information can be obtained by **coupling the chemistry solver to an electron Boltzmann equation (EBE) solver**, typically adopting the classical two-term expansion.

In most cases this coupling involves several approximations (possibly due to the **lack of readily available time-dependent EBE solvers**): introducing **effective source terms** [5] that account for the electron-impact creation of excited species, or considering a **quasi-stationary situation for electrons** [6,7] solving a time-independent form of the EBE for different instantaneous values of the reduced electric field, E/N .

Time-dependent EBE (two-term expansion)

Under the **classical two-term expansion**, and considering a space-independent **exponential temporal growth for the electron density**, the **time-dependent EBE** writes as follows:

$$\frac{1}{N} \frac{\partial f(u, t)}{\partial t} + \frac{\langle \nu_{eff} \rangle}{N} f(u, t) + \frac{1}{N\sqrt{u}} \frac{\partial (G_{el}(u, t) + G_E(u, t))}{\partial u} = \sqrt{\frac{2e}{m_e u}} S(u, t) \quad \text{Isotropic component equation}$$

$$f^1(u, t) = - \frac{1}{\sigma_c(u) + \sqrt{\frac{m_e \langle \nu_{eff} \rangle}{2eu}}} \frac{E(t)}{N} \frac{\partial f(u, t)}{\partial u} \quad \text{Anisotropic component equation}$$

$$G_{el}(u, t) = - \sum_k 2 \frac{m_e}{M_k} \nu_{k,c}^{el}(u) u^{3/2} \left[f(u, t) + \frac{k_B T_g}{e} \frac{\partial f(u, t)}{\partial u} \right] \longrightarrow \text{Elastic collision operator}$$

$$G_E(u, t) = N \sqrt{\frac{2e}{m_e}} \frac{u E(t)}{3 N} f^1(u, t) \longrightarrow \text{Electric field operator}$$

$$S_{i,j}(u, t) = \delta_i [(u + V_{i,j}) \sigma_{i,j}(u + V_{i,j}) f(u + V_{i,j}, t) - u \sigma_{i,j}(u) f(u, t)] + \delta_j \frac{g_i}{g_j} [u \sigma_{i,j}(u) f(u - V_{i,j}, t) - (u + V_{i,j}) \sigma_{i,j}(u + V_{i,j}) f(u, t)] \longrightarrow \text{Inelastic collision operator}$$

The **anisotropic component** of the electron distribution function is **assumed to be in steady-state** because:

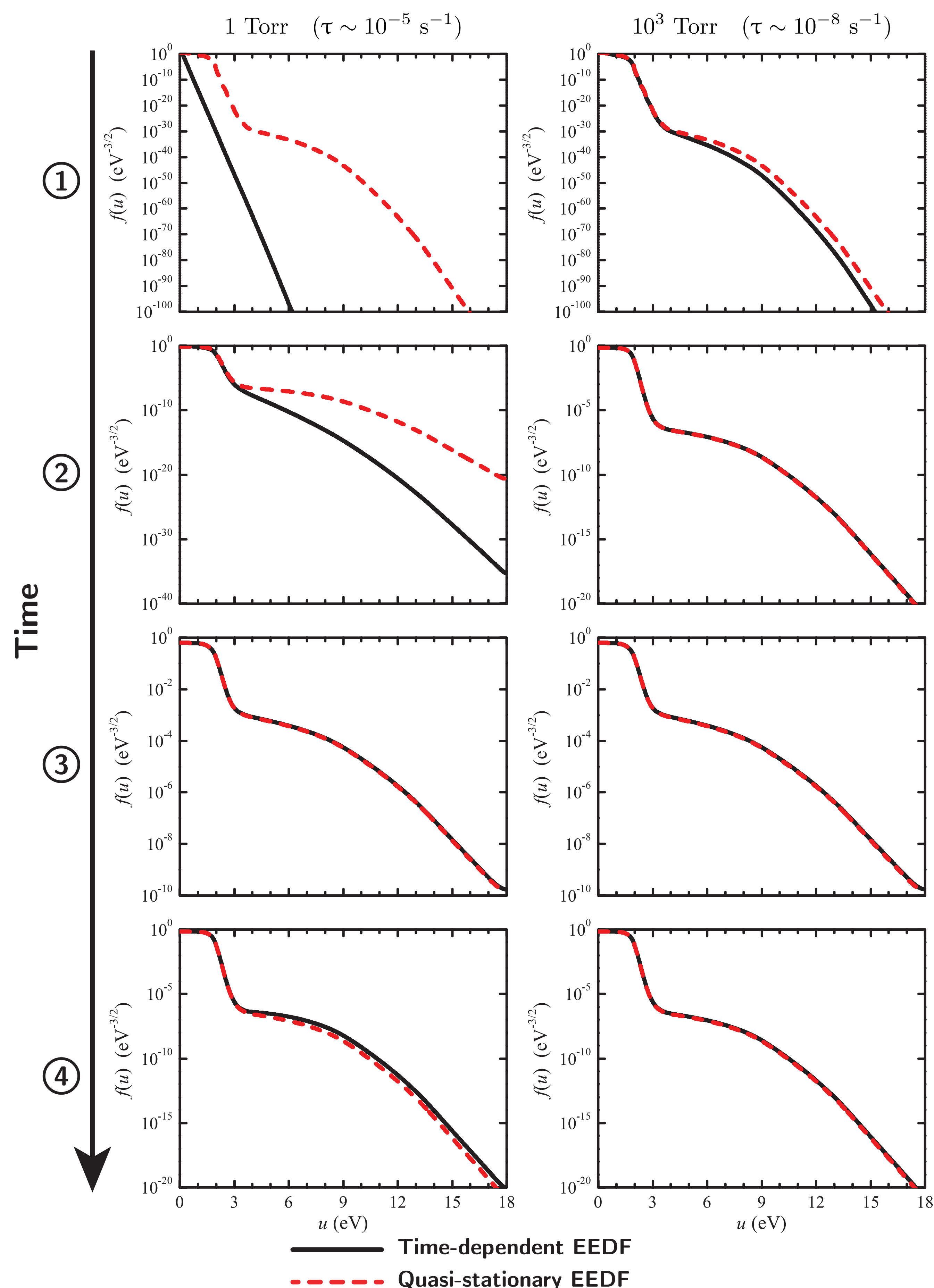
$$\text{Characteristic reaction time of the isotropic component of the EDF } \tau \sim \frac{1}{\sum_k \frac{m_e}{M_k} \nu_{k,c}^{el}} \gg \frac{1}{\sum_k \nu_{k,c}^{el}} \sim \tau_1 \quad \text{Characteristic reaction time of the isotropic component of the EDF}$$

In order to **neglect the temporal derivative of the isotropic equation** (i.e. quasi-stationary solution), the **characteristic reaction time** of the isotropic component of the EDF has to be **much shorter than the characteristic time of the excitation**.

$$\frac{10^{18} \text{ m}^{-3} \text{ s}^{-1}}{N} \sim \tau \ll \tau_{exc} \Leftrightarrow \text{Quasi-stationary solution}$$

Comparison of quasi-stationary and time-dependent calculations

We have studied the test case of a **fast-pulsed discharge in dry air**, 80% N₂ - 20% O₂, including **vibrational distributions for both gases**, N₂(X,v) and O₂(X,v), given by Boltzmann distributions at gas temperature, T_g = 300 K, for two different pressures **1 Torr and 10³ Torr**. The electron kinetics has been solved assuming either a quasi-stationary situation or solving the time-dependent EBE.



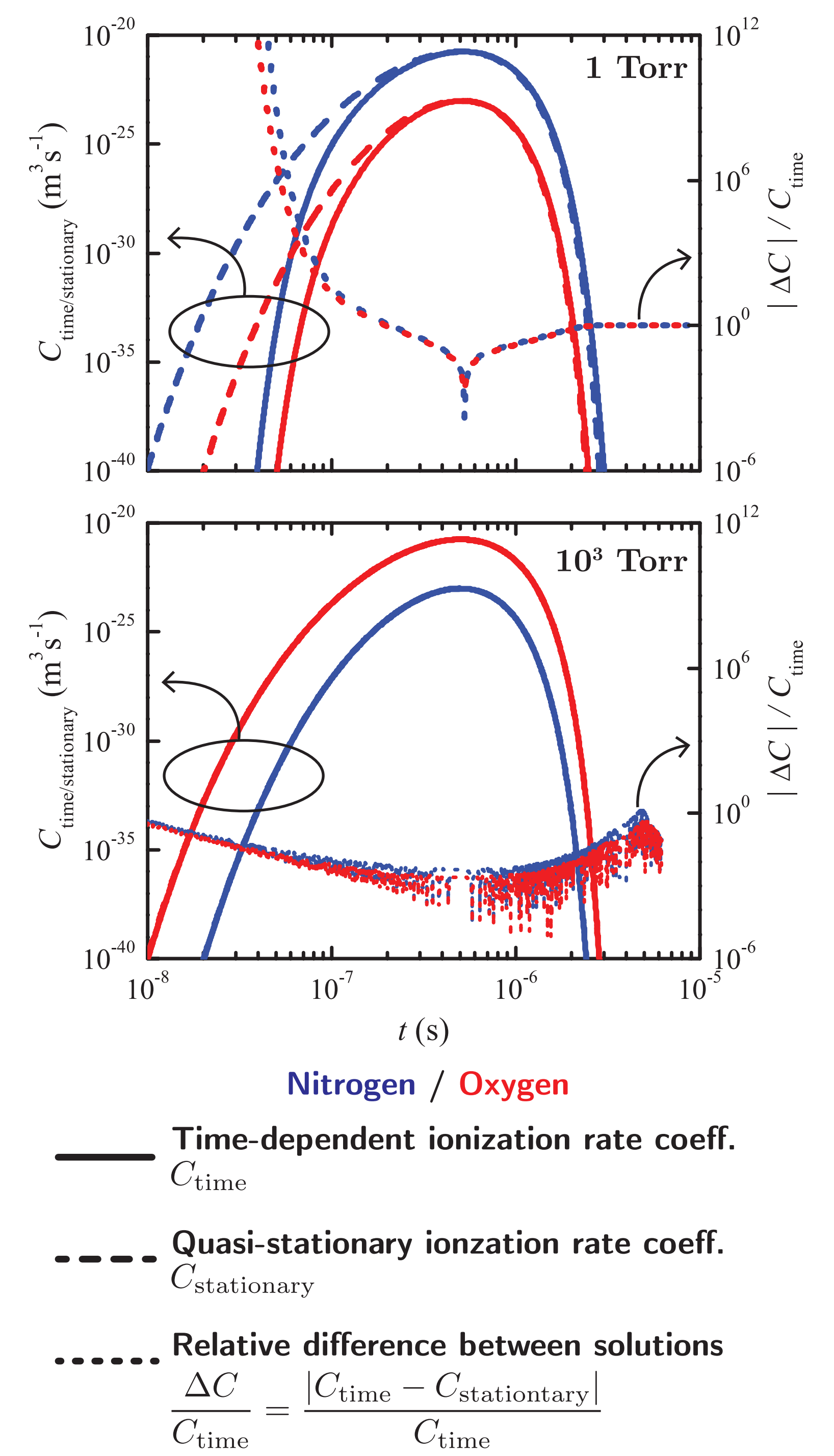
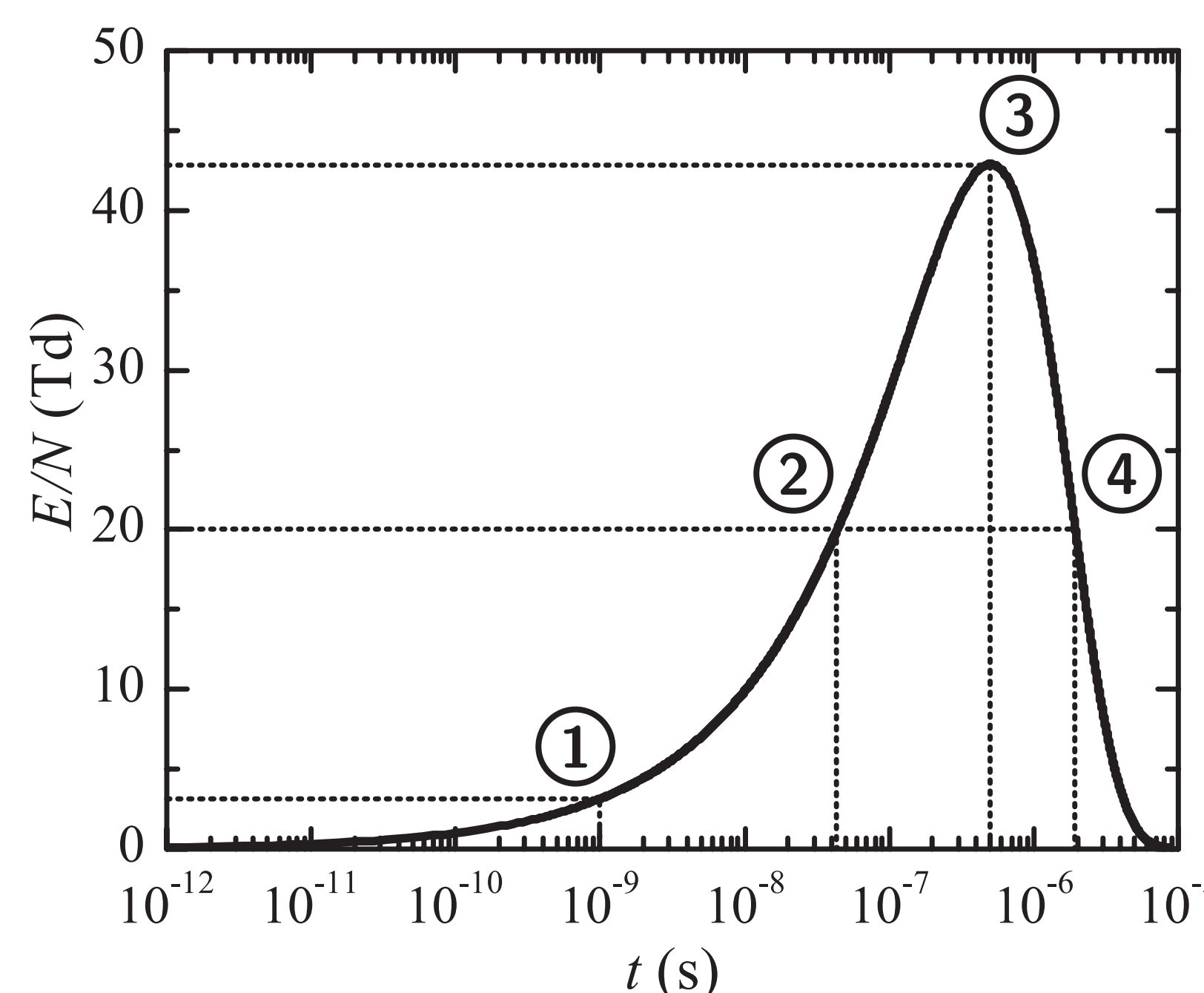
The implementation of the models is as follows:

- **Quasi-stationary solution:** solution of the time-independent LoKI-B considering 1000 values of E/N logarithmically separated in the range 0-45 Td, then using linear interpolations to describe the time-dependent electron kinetics.

- **Time-dependent solution:** solution of the time-dependent LoKI-B directly using the time evolution of the electric field.

The **electric field pulse** is given by the following expression:

$$\frac{E(t)}{N} = 100 \sqrt{\frac{t(s)}{10^{-6}}} \exp\left(-\frac{t(s)}{10^{-6}}\right) \text{ (Td)} \quad (\tau_{exc} \sim 10^{-6})$$



Conclusions

The open-source code **LoKI-B** has been updated in order to solve the temporal evolution of the EBE during an electric field pulse. We have studied the electron kinetics during a **fast-pulsed discharge in air** considering either a **quasi-stationary** or a **time-dependent** solution for the cases of **low and high pressures**. The present results evidence the **limitations of using the quasi-stationary approach in the μs timescale for low-pressure discharges**. It was also shown that **for high-pressure discharges the quasi-stationary approach is applicable in the μs timescale**. However, it has to be noticed that **in both cases the quasi-stationary solution fails in the ns timescale**.

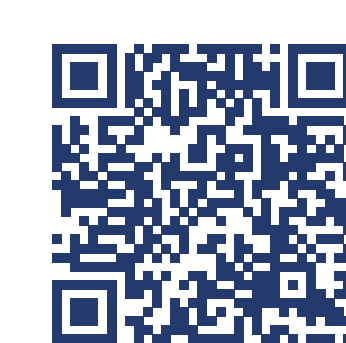
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